

	Type	L #	Hits	Search Text	DBs	Time Stamp
1	BRS	L1	51	438/265.ccls. and silicide and @ay<2001	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/29 12:49
2	BRS	L2	286	438/595.ccls. and silicide and @ay<2001	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/29 13:03
3	BRS	L3	102	438/630.ccls. and silicide and @ay<2001	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/29 13:06
4	BRS	L4	1214	438/655.ccls. and silicide and @ay<2001	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/29 13:51
5	BRS	L5	319	4 and (side adj wall (sidewall))	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/29 13:07
6	BRS	L6	319	4 and ((side adj wall) (sidewall))	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/29 13:07

	Type	L #	Hits	Search Text	DBs	Time Stamp
7	BRS	L7	342	438/664.ccls. and silicide and @ay<2001	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/29 13:55
8	BRS	L8	158	7 and (sidewall (side adj wall))	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/29 13:52
9	BRS	L9	317	438/682.ccls. and silicide and @ay<2001	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/29 13:55
10	BRS	L10	155	9 and (sidewall (side adj wall))	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/29 14:03
11	BRS	L11	28	silicide adj spacer	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/29 14:04

	Typ	L #	Hits	Search Text	DBs	Time Stamp
1	BRS	L1	0	438/265.ccls. and silicde and @ay<2001	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/29 08:31
2	BRS	L2	51	438/265.ccls. and silicide and @ay<2001	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/29 08:49
3	BRS	L3	286	438/595.ccls. and silicide and @ay<2001	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/29 10:03
4	BRS	L4	102	438/630.ccls. and silicide and @ay<2001	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/29 10:14
5	BRS	L5	1214	438/655.ccls. and silicide and @ay<2001	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/29 10:25
6	BRS	L6	110	5 and (side adj wall)	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/29 10:15

	Type	L #	Hits	Search Text	DBs	Time Stamp
7	BRS	L7	342	438/664.ccls. and silicide and @ay<2001	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/29 10:33
8	BRS	L8	44	7 and (side adj wall)	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/29 10:29
9	BRS	L9	124	7 and (sidewall)	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/29 10:29
10	BRS	L10	317	438/682.ccls. and silicide and @ay<2001	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/29 10:50
11	BRS	L11	155	10 and (sidewall (side adj wall))	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/29 10:34
12	BRS	L12	24	438/755.ccls. and silicide and @ay<2001	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/29 10:57

	Type	L #	Hits	Search T xt	DBs	Time Stamp
13	BRS	L13	973	etch and (second adj (sidewall (side adj wall)))	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/29 10:59
14	BRS	L14	453	13 and silicide	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/29 11:33
15	IS&R	L15	6	(("6111292") or ("6057194") or ("4897703")).PN.	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/29 11:33

	Type	L #	Hits	Search T xt	DBs	Time Stamp
1	BRS	L1	69	(fet mosfet) and silicide and sidewall and spacer and trench and (second adj sidewall)	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/26 12:07
2	BRS	L2	51	438/265.ccls. and silicide and @ay<2001	USPAT; EPO; JPO; DERWEN T; IBM_TD B	2004/01/26 12:08